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Tack-and-Cure without Pressure High Moisture Resistance Electrically Insulating Epoxy Film Adhesive

IDEAL FOR:

High Volume, Automated Assemblies Die Attach Low Dielectric Constant (3.0) Low Dielectric Loss (<0.002)

DESCRIPTION:

ESP7660-HK is a high-bond strength epoxy film adhesive for die-attach application. This die attach film (DAF) can be laminated onto the back of the wafer at 70 $^{\circ}\text{C}$ and then mounted onto a standard dicing tape on a supporting frame. The wafer and the DAF can then be diced into predetermined sizes. This new generation wafer level die-attach film (DAF) is flexible for easy pick-and-place application before the final curing step.

After dicing, the chip can be picked and placed directly onto a leadframe or a substrate. The adhesive can then be cured according to one of the cure schedules. The dry, tack-free handling of the film makes it suitable for an automated assembly.

AVAILABILITY:

ESP7660-HK is available in sheet sizes or rolls. Standard thickness of ESP7660-HK is 20 micron thick. Special thicknesses are available upon request.

APPLICATION PROCEDURES:

- (1) Keep product in aluminum polylaminate protective bag when not in use.
- (2) Before using, remove protective liner from film. Place wafer onto adhesive film side.
- (3) Laminate (low heat of 60-80 $^{\rm o}{\rm C}$) wafer onto adhesive until good wetting is achieved. Dice wafer as usual.
- (4) Once dicing is complete, the die can be picked and placed onto a leadframe or substrate. Cure according to one of the recommended schedules.

Die Attach Film ESP7660-HK

TYPICAL PROPERTIES*

Electrical Resistivity >1 x 10 14 ohm-cm

(150 °C/60 minutes)

Dielectric Strength (Volts/mil) > 750
Glass Transition Temp.(°C) 175 ±10%

Current Carrying Capabilities N/A Lap-Shear Strength N/A

Device Push-off Strength >2500 psi

>17.1 N/mm²

Hardness (Type) 85 (D) $\pm 10\%$ Cured Density (gm/cc) 1.6 $\pm 10\%$

Thermal Conductivity 2 Btu-in/hr-ft²-°F ±10%

0.3 W/m-°C ±10%

Linear Thermal Expansion 4

40 ±10%

Coeff. (ppm/°C)

Maximum Continuous Operation Temp. (°C) <150

CURE SCHEDULES:

<u>Temperature</u>	<u>Time</u>	<u>Pressure</u>
100°C	4hr	10-15 psi
125°C	2hr	5-15 psi
150°C	1hr	5-15 psi

The die or component can also be tacked on the substrate at 80°C or higher with 5 psi. When a fillet around the edge of the die or component is observed, the pressure can be released for the rest of the bonding cycle.

SHELF LIFE:

Storage temperature Shelf Life

25 °C 1 yr

in sealed package

Floor Life >180 days @25 C

CAUTION: This product may cause skin irritation. Avoid skin contact. If contact does occur, wash immediately with soap and water. Please refer SDS for more details.

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PRODUCT DATA SHEET Ver 2.1 05/16/2019

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